



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

April 17, 2026

IGI Report Number

Description

Shape and Cutting Style

Measurements

LG792611702

LABORATORY GROWN DIAMOND

OVAL BRILLIANT

9.69 X 6.52 X 4.06 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

1.58 CARAT

D

VVS 2

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)

EXCELLENT

EXCELLENT

NONE

 LG792611702

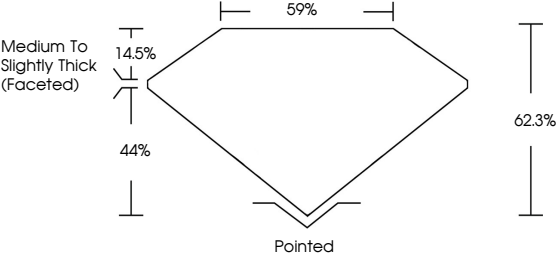
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LABORATORY GROWN DIAMOND REPORT

LG792611702

Report verification at [igi.org](https://www.igi.org)

PROPORTIONS

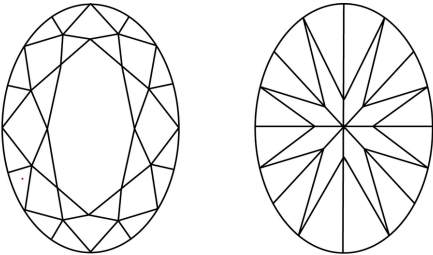


Medium To Slightly Thick (Faceted)

Sample Image Used



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS 1-2 VS 1-2 SI 1-2 I 1-3

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)

EXCELLENT

EXCELLENT

NONE

 LG792611702

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IGI

April 17, 2026

IGI Report No LG792611702

OVAL BRILLIANT

9.69 X 6.52 X 4.06 MM

Carat Weight

Color Grade

Clarity Grade

Depth

Table

Girdle

Medium to Slightly Thick (Faceted)

Pointed

Polish

Symmetry

Fluorescence

Inscription(s)

1.58 CARAT

D

VVS 2

62.3%

59%

EXCELLENT

EXCELLENT

NONE

 LG792611702

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